

Search Notes

Application/Control No.

10/605,726

Examiner

Stephen W. Smoot

Applicant(s)/Patent under
Reexamination

ZHU ET AL.

Art Unit

2813

SEARCHED

Class	Subclass	Date	Examiner
438	151	2/5/2005	SWS
438	270	2/5/2005	SWS
438	295	2/5/2005	SWS
438	300	2/5/2005	SWS
438	589	2/5/2005	SWS
438	595	2/5/2005	SWS
257	347	2/5/2005	SWS
257	387	2/5/2005	SWS

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**Key Words: SOI - BOX, SiGe, Silicon
Epitaxial Layer;

2/5/2005

S.W.S.

Elevated Source/Drain - Raised;
Recessed Gate - Trench, Groove,
Damascene, Inlaid.

2/5/2005

S.W.S.

Search Tools - EAST (attached):
USPAT; US PG PUBS; Derwent;
EPO; JPO; IBM TDB

2/5/2005

S.W.S.